

## **AMENDMENTS TO THE CLAIMS:**

This listing of claims will replace all prior versions and listings of claims in the application:

1-10. (Cancelled).

11. (New) A method for making polishing abrasive particles for use in a final stage of a fine polishing process, the method comprising condensing an alkoxysilane in the presence of an acid catalyst to form an alkoxysilane condensate having an average degree of condensation of from 2 to 8 and then hydrolyzing the alkoxysilane condensate in the presence of an ammonia or ammonium salt catalyst to form cocoon-shaped colloidal silica as the polishing abrasive particles.

12. (New) The method of claim 11, wherein the cocoon-shaped colloidal silica formed is heated under pressure.

13. (New) The method of claim 12, wherein temperature to which said colloidal silica is heated under pressure is 105 to 374.1°C.

14. (New) The method of claim 11, wherein the alkoxysilane condensate is hydrolyzed by continuously adding the alkoxysilane condensate or a solution thereof in an aqueous solvent to an aqueous solution of ammonia or an ammonium salt or to an aqueous solution containing ammonia or an ammonium salt and an aqueous solvent.

15. (New) Polishing abrasive particles for use in a final stage of a fine polishing process comprising cocoon-shaped silica made by the method of any one of claims 11-14.